

Supporting Information for

**Assessing negative thermal expansion in mesoporous metal-organic frameworks by molecular simulation**

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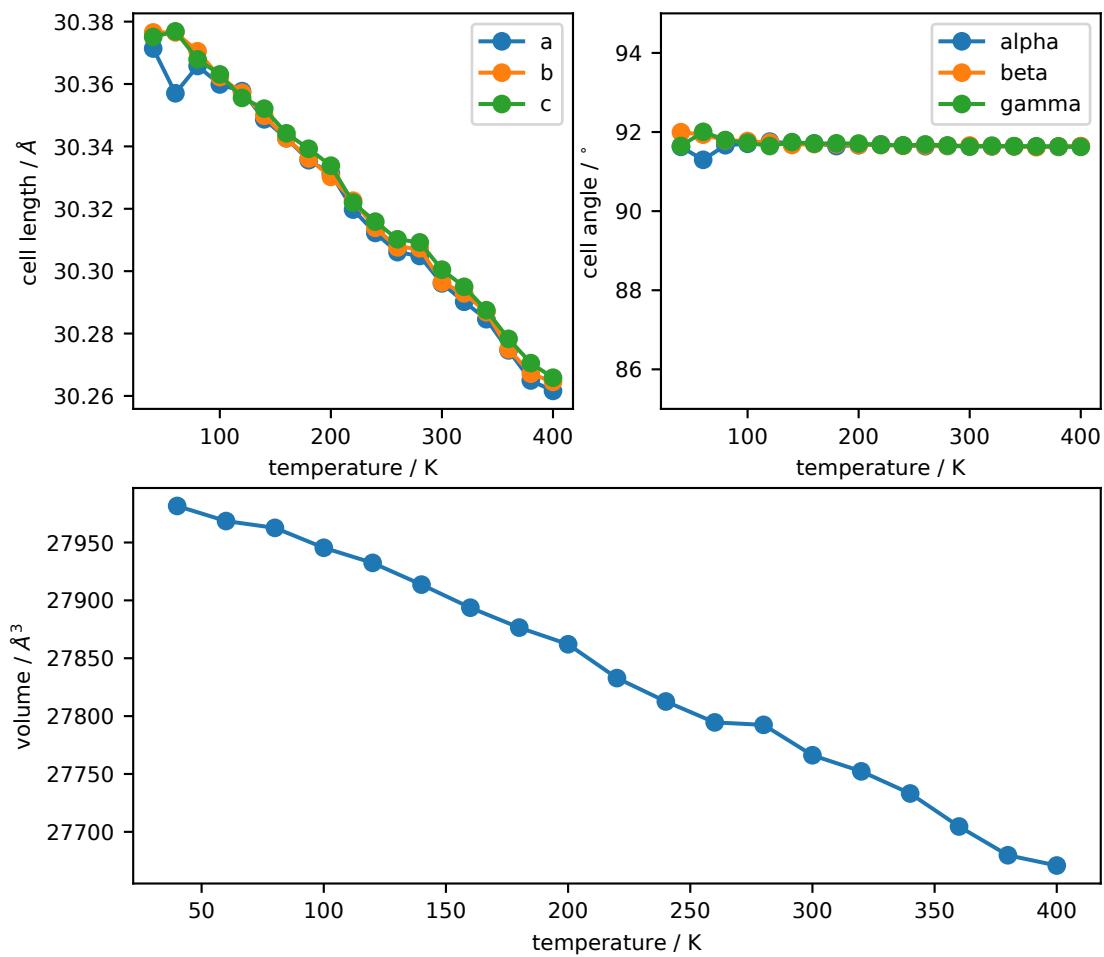
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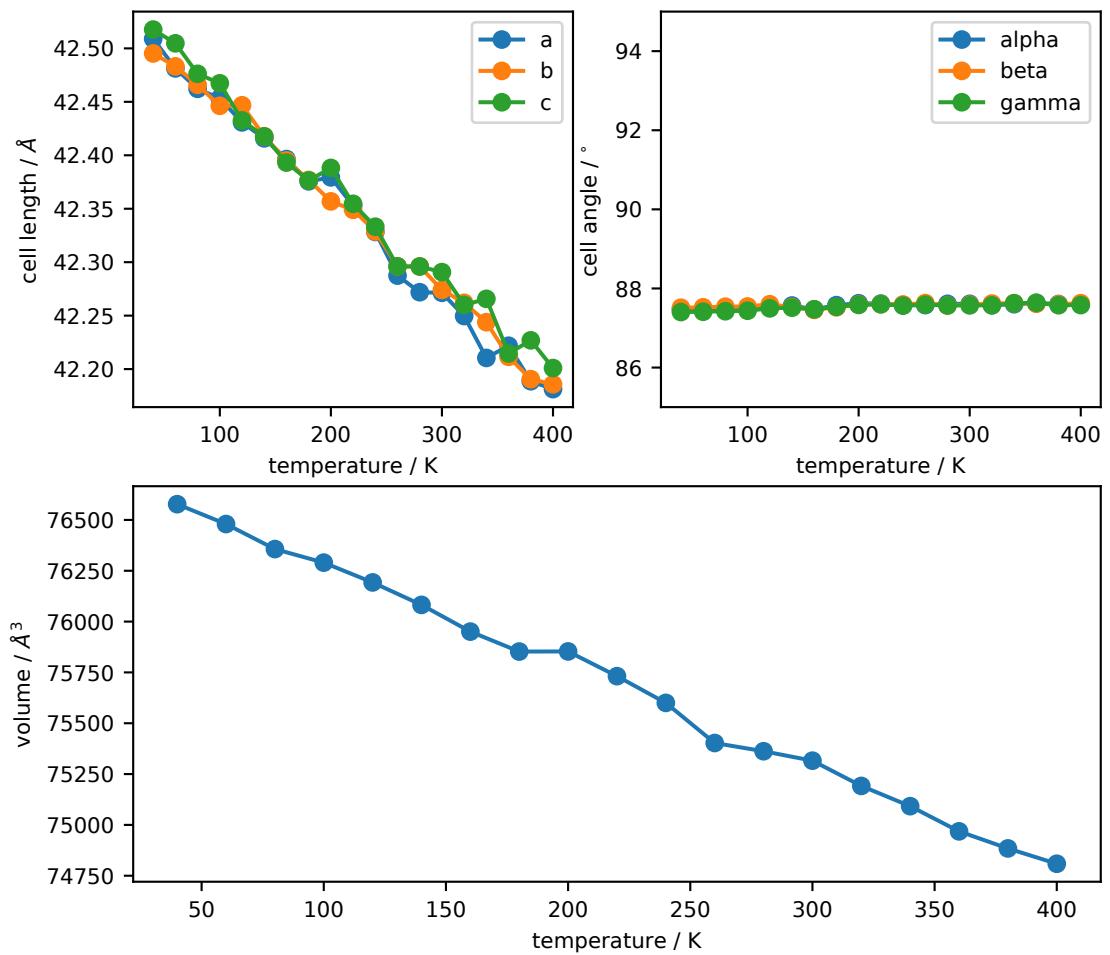
**Table S1** Comparison of simulated lattice parameters to experimentally reported data

	a,b,c / Å	$\alpha, \beta, \gamma / {}^\circ$	Reference
DUT-6	30.245 (30.3)	90.0 (91.7)	[S1]
DUT-60	42.650 (42.3)	90.0 (87.6)	[S2]
MOF-210 <sup>†</sup>	71.1, 50.9 (72.4, 52.3)	60, 110.9 (60.0, 111.2)	[S3]
DUT-49	46.588 (46.5)	90.0 (90.0)	[S4]
MOF-399	68.3112 (67.5)	90.0 (90.0)	[S5]
PCN-68	59.153 (60.2)	90.0 (90.0)	[S6]
NU-110	68.706 (70.4)	90.0 (90.0)	[S7]

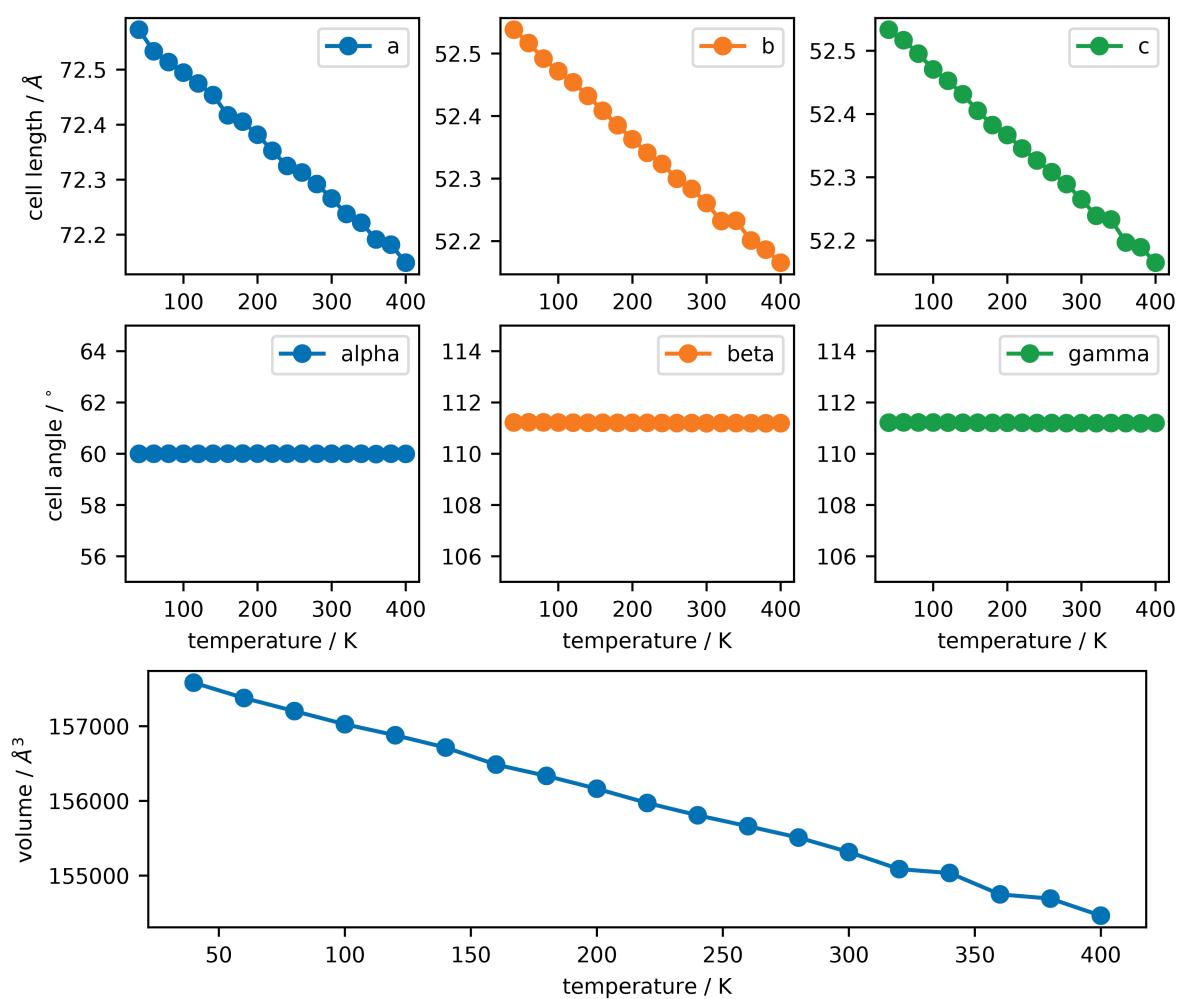
<sup>†</sup>This cell was transformed from the primitive cell using the box flip routine in lammps



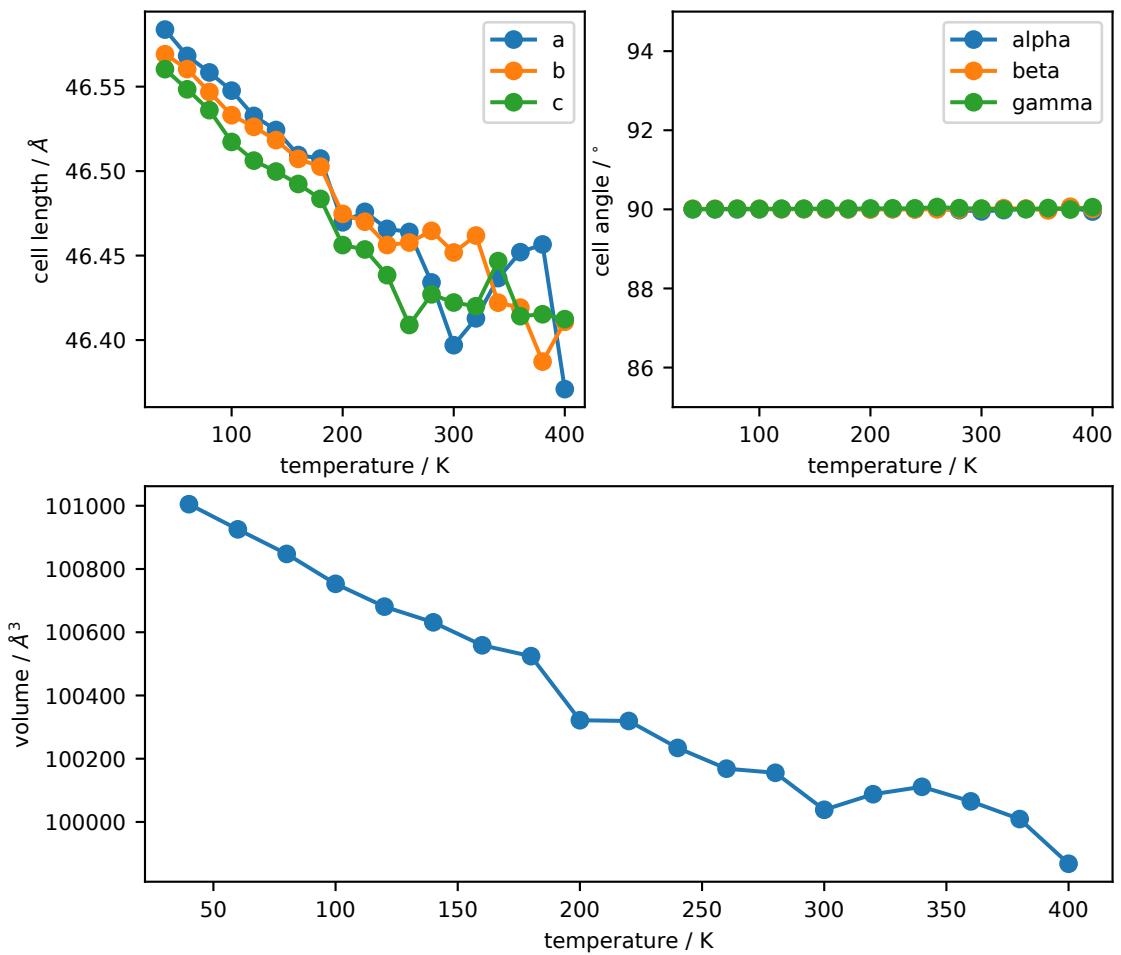
**Fig. S1** Average cell parameters and volume of DUT-6 in response to increasing temperature.



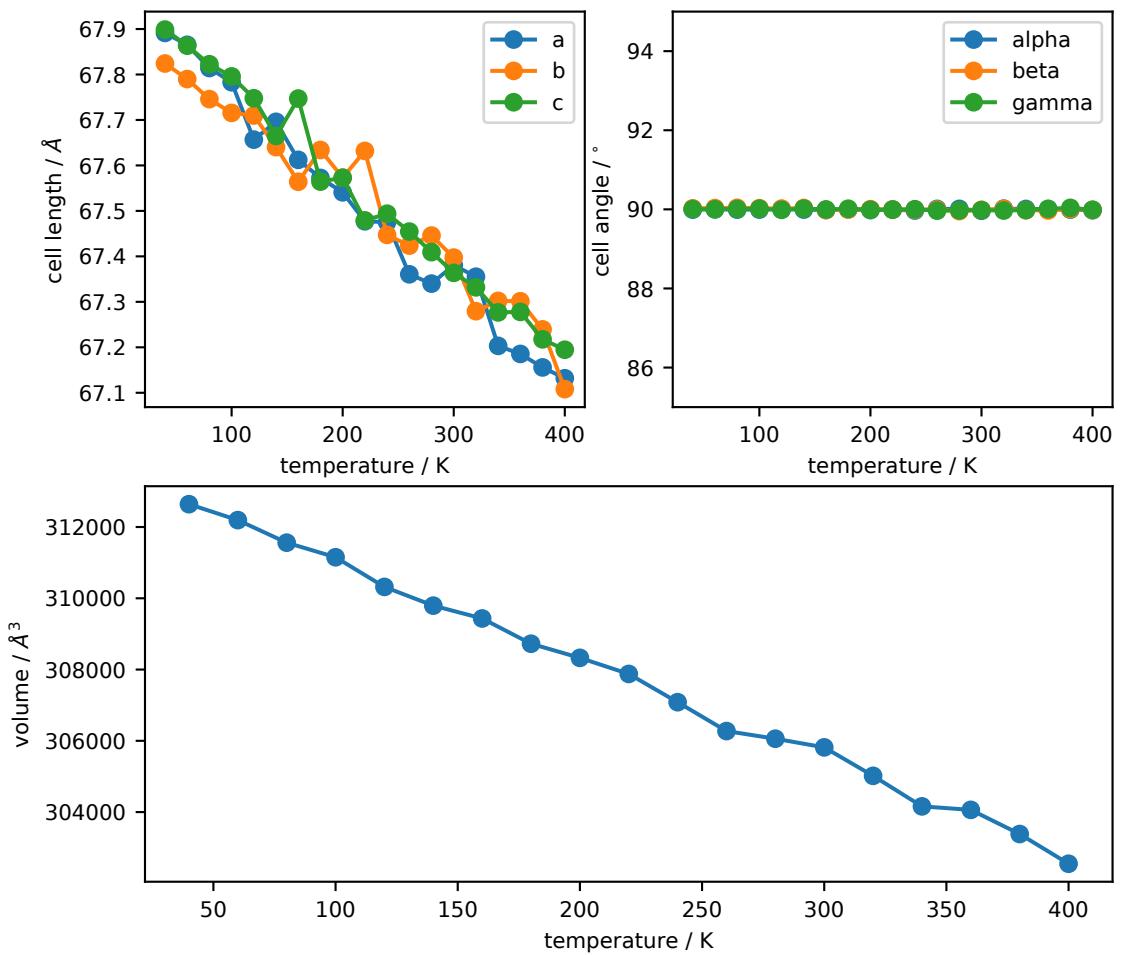
**Fig. S2** Average cell parameters and volume of DUT-60 in response to increasing temperature.



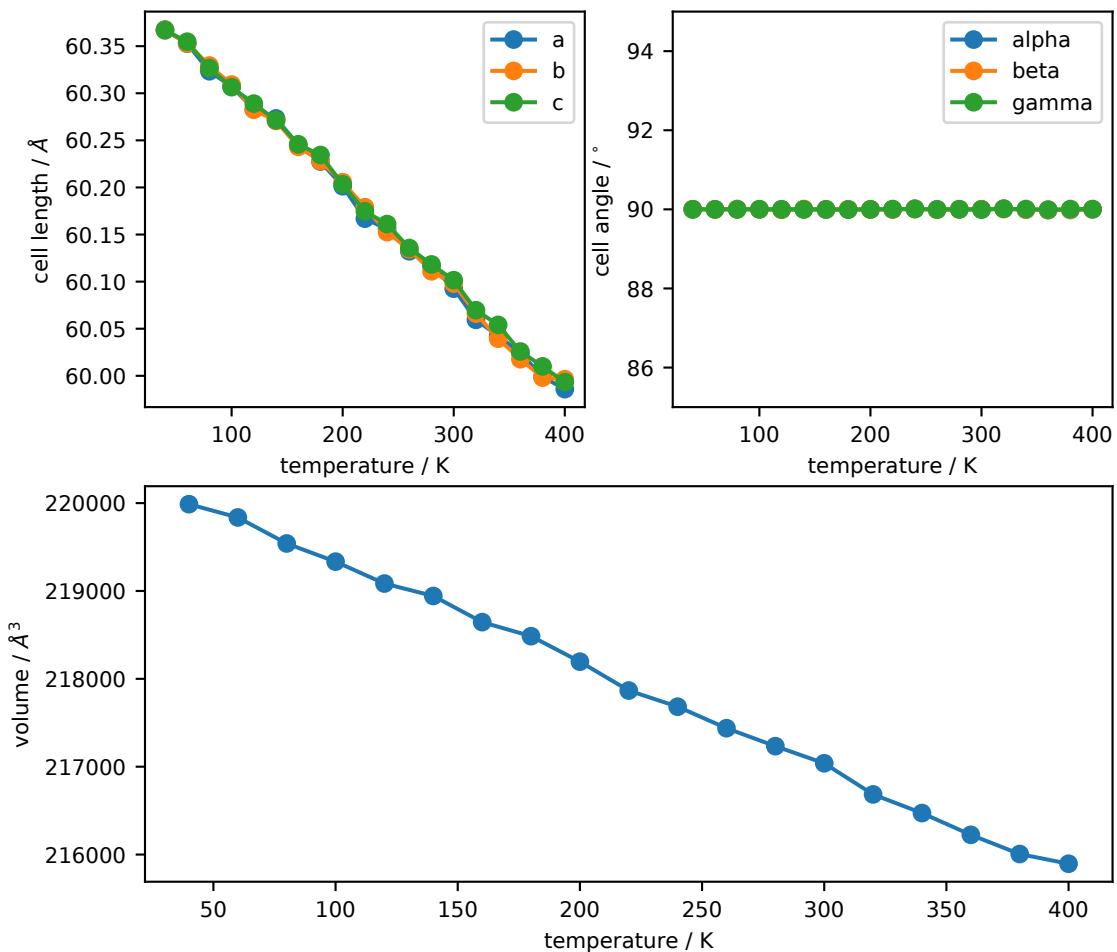
**Fig. S3** Average cell parameters and volume of MOF-210 in response to increasing temperature.



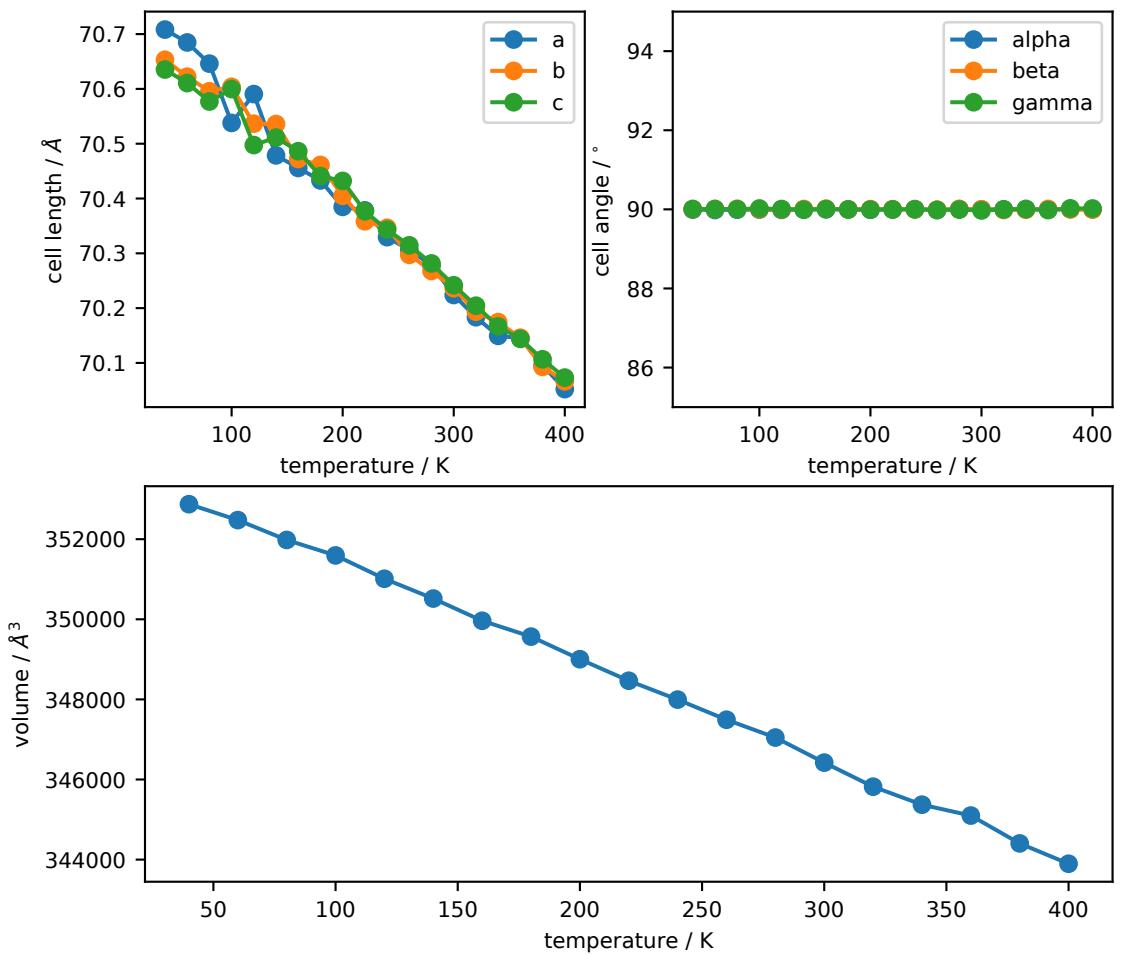
**Fig. S4** Average cell parameters and volume of DUT-49 in response to increasing temperature.



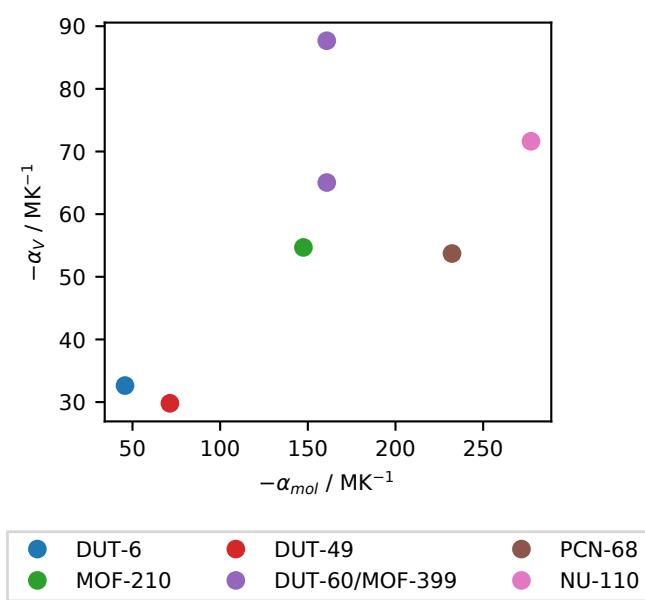
**Fig. S5** Average cell parameters and volume of MOF-399 in response to increasing temperature.



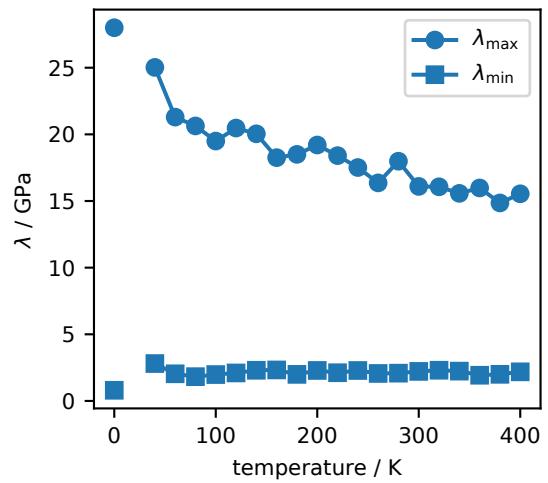
**Fig. S6** Average cell parameters and volume of PCN-68 in response to increasing temperature.



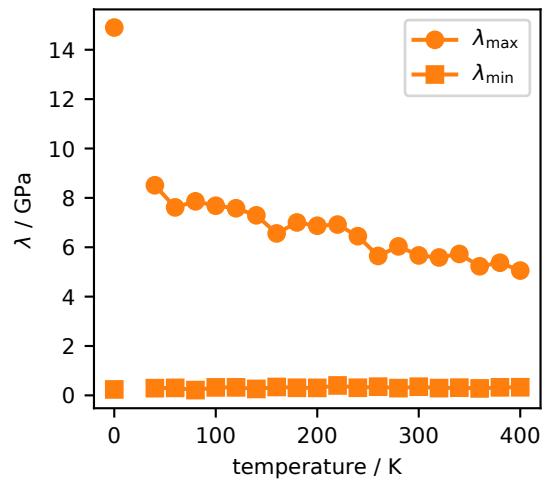
**Fig. S7** Average cell parameters and volume of NU-110 in response to increasing temperature.



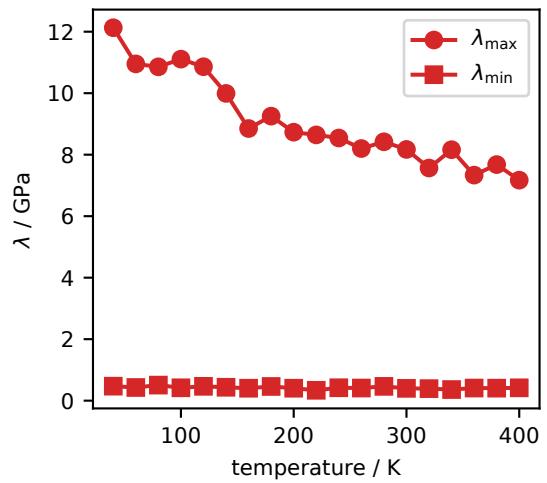
**Fig. S8** Correlation between molecular coefficient of expansion,  $\alpha_{\text{mol}}$ , and volumetric coefficient of expansion,  $\alpha_V$ .



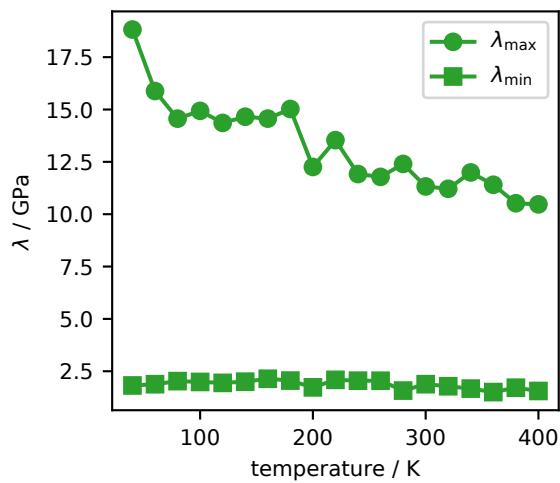
**Fig. S9** Maximum and minimum ( $\lambda_{\max}$  and  $\lambda_{\min}$ ) eigenvalues of the stiffness matrix for DUT-6 over the studied temperature range. Values at 0 K correspond to DFT simulation reported previously.<sup>S2</sup>



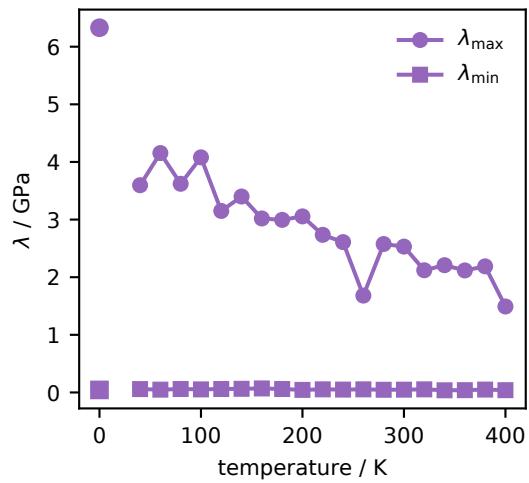
**Fig. S10** Maximum and minimum ( $\lambda_{\max}$  and  $\lambda_{\min}$ ) eigenvalues of the stiffness matrix for DUT-60 over the studied temperature range. Values at 0 K correspond to DFT simulation reported previously.<sup>S2</sup>



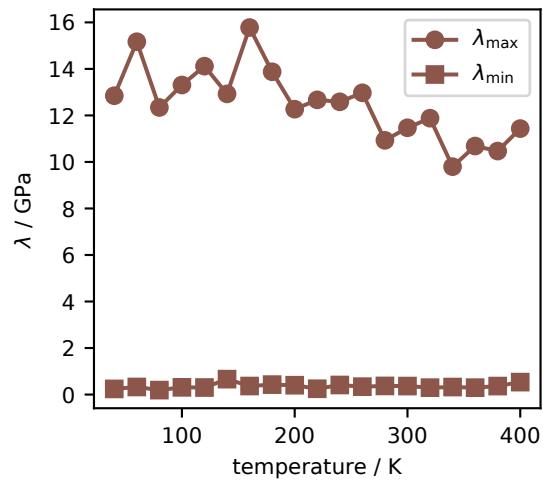
**Fig. S11** Maximum and minimum ( $\lambda_{\max}$  and  $\lambda_{\min}$ ) eigenvalues of the stiffness matrix for MOF-210 over the studied temperature range.



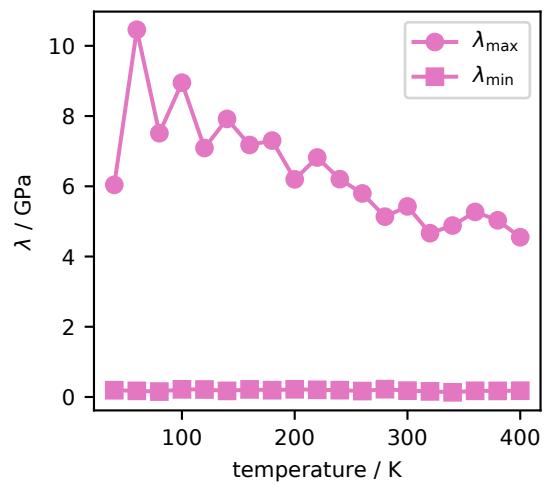
**Fig. S12** Maximum and minimum ( $\lambda_{\max}$  and  $\lambda_{\min}$ ) eigenvalues of the stiffness matrix for DUT-49 over the studied temperature range.



**Fig. S13** Maximum and minimum ( $\lambda_{\max}$  and  $\lambda_{\min}$ ) eigenvalues of the stiffness matrix for MOF-399 over the studied temperature range. Values at 0 K correspond to DFT simulation reported previously.<sup>S2</sup>



**Fig. S14** Maximum and minimum ( $\lambda_{\max}$  and  $\lambda_{\min}$ ) eigenvalues of the stiffness matrix for PCN-68 over the studied temperature range.



**Fig. S15** Maximum and minimum ( $\lambda_{\max}$  and  $\lambda_{\min}$ ) eigenvalues of the stiffness matrix for NU-110 over the studied temperature range.

## References

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